

## $\alpha$ -RuCl<sub>3</sub>/Pt における磁気抵抗効果

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### Magnetoresistance in an $\alpha$ -RuCl<sub>3</sub>/Pt

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#### Introduction

Recently an  $\alpha$ -RuCl<sub>3</sub> has emerged as a primal candidate for hosting a Kitaev Quantum Spin Liquid [1] and has been attracting great attentions. In this study, we investigated the magnetoresistance [2] in Pt/ $\alpha$ -RuCl<sub>3</sub> bilayers at low temperatures where the Kitaev QSL state and zigzag antiferromagnetic state [3] are expected to emerge.

#### Experimental method

We transferred an  $\alpha$ -RuCl<sub>3</sub> flake on a SiO<sub>2</sub> substrate by exfoliating with the Scotch tape and then deposited 3 nm-thick Pt on top of it. The bilayer was patterned into a 50  $\mu$ m wide Hall bar using e-beam lithography technique. The rotation angles ( $\alpha, \beta, \gamma$ ) and the measurement configurations are defined in Fig. 1(a).

#### Experimental results

Fig. 1(b) shows the temperature dependence of magnetoresistance normalized to the base corresponding resistance ( $\Delta R_{xx}/R_{xx} = \Delta\rho_{xx}/\rho_{xx}$ ) obtained for the three field rotations. Below 50 K,  $\Delta\rho_{xx}/\rho_{xx}$  increase with decreasing temperature for both  $-\beta$  and  $-\gamma$  rotations. In the presentation, we will discuss the temperature dependence of  $\Delta\rho_{xx}/\rho_{xx}$  with respect to the temperature dependence of magnetic state of an  $\alpha$ -RuCl<sub>3</sub>.

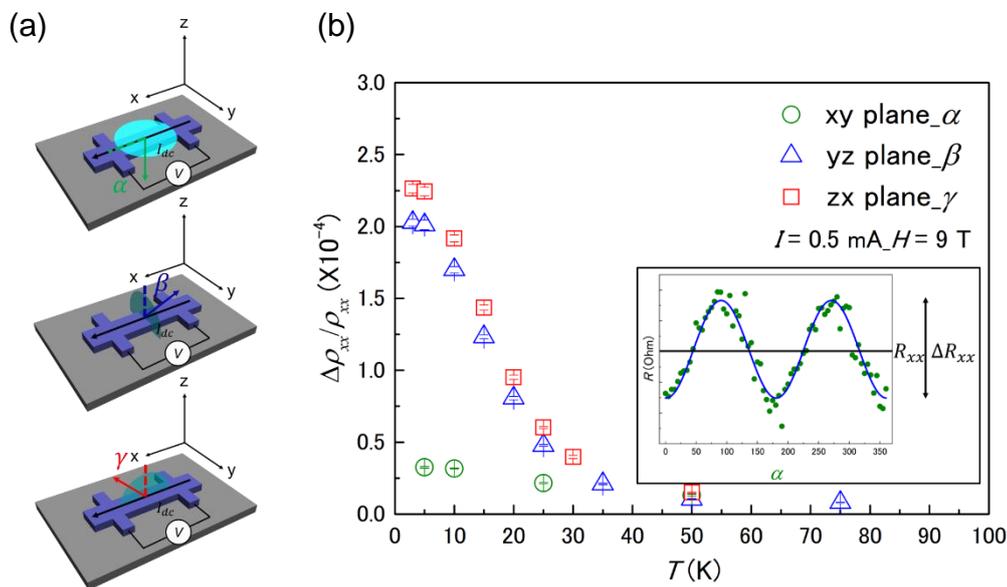


Fig. 1 (a) The measurement configurations. (b) Temperature dependence of  $\Delta\rho_{xx}/\rho_{xx}$  obtained at 9 T. Inset: the angular dependence of the longitudinal resistance  $R_{xx}(\alpha)$  at 5 K.

[1] A. Kitaev, Ann. Phys. **321**, 2 (2006).

[2] H. Nakayama *et al.*, Phys. Rev. Lett. **110** 206601 (2013).

[3] R. D. Johnson *et al.*, Phys. Rev. B **92** 235119 (2015).